

MAR 18 2005

Applicant:	Jaiswal	Docket No:	TI-34403.1
Serial No:	10/679,783	Examiner:	McDonald, Rodney Glenn
Filed:	10/6/2003	Art Unit:	1753
For:	CONTROL OF NICHROME RESISTOR TEMPERATURE COEFFICIENT USING RF PLASMA SPUTTER ETCH		

Topunie Chambers

PAGE 2/7 * RCVD AT 3/18/2005 5:31:38 PM (Eastern Standard Time) * 8VR:USPTO-EFXRF-1/4 * DMS:8729308 * CSID:972 917 4417 * DURATION (mm:ss):02:12